# VE320 Intro to Semiconductor Devices RC Week8

Yucheng Huang

University of Michigan Shanghai Jiao Tong University Joint Institute

July 1, 2022

- 1 The pn Junction Diode
  - pn Junction Current
  - Generation—Recombination Currents
  - High-Level Injection

- The pn Junction Diode
  - pn Junction Current
  - Generation—Recombination Currents
  - High-Level Injection

#### pn Junction Current

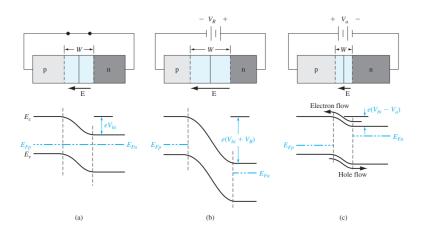


Figure: A pn junction and its associated energy-band diagram for (a) zero bias, (b) reverse bias, and (c) forward bias

#### pn Junction Current

The ideal current-voltage relationship of a pn junction is derived on the basis of four assumptions. (The last assumption has three parts, but each part deals with current.) They are:

- 1. The abrupt depletion layer approximation applies. The space charge regions have abrupt boundaries, and the semiconductor is neutral outside of the depletion region.
- 2. The Maxwell-Boltzmann approximation applies to carrier statistics.
- 3. The concepts of low injection and complete ionization apply.
- 4a. The total current is a constant throughout the entire pn structure.
- 4b. The individual electron and hole currents are continuous functions through the pn structure.
- 4c. The individual electron and hole currents are constant throughout the depletion region.

An expression for the built-in potential barrier was derived in the last chapter and was given by Equation (7.10) as

$$V_{bi} = V_t \ln \left( \frac{N_a N_d}{n_i^2} \right)$$

If we divide the equation by  $V_t = kT/e$ , take the exponential of both sides, and then take the reciprocal, we obtain

$$\frac{n_i^2}{N_a N_d} = \exp\left(\frac{-eV_{bi}}{kT}\right)$$

If we assume complete ionization, we can write

$$n_{n0} \approx N_d$$

where  $n_{n0}$  is the thermal-equilibrium concentration of majority carrier electrons in the n region. In the p region, we can write

$$n_{p0} pprox rac{n_i^2}{N_a}$$

where  $n_{p0}$  is the thermal-equilibrium concentration of minority carrier electrons. Substituting Equations into Equation 1, we obtain

$$n_{p0} = n_{n0} \exp\left(\frac{-eV_{bi}}{kT}\right)$$

The potential barrier  $V_{bi}$  in Equation can be replaced by  $(V_{bi}-V_a)$  when the junction is forward biased. Equation becomes

$$n_p = n_{n0} \exp\left(\frac{-e\left(V_{bi} - V_a\right)}{kT}\right) = n_{n0} \exp\left(\frac{-eV_{bi}}{kT}\right) \exp\left(\frac{+eV_a}{kT}\right)$$

If we assume low injection, the majority carrier electron concentration  $n_{n0}$ , for example, does not change significantly. However, the minority carrier concentration,  $n_p$ , can deviate from its thermal-equilibrium value  $n_{p0}$  by orders of magnitude. Using Equation, we can write Equation as

$$n_p = n_{p0} \exp\left(\frac{eV_a}{kT}\right)$$

Exactly the same process occurs for majority carrier holes in the p region, which are injected across the space charge region into the n region under a forward-bias voltage. We can write that

$$p_n = p_{n0} \exp\left(\frac{eV_a}{kT}\right)$$

## Example 1

Consider a silicon pn junction at  $T=300~\mathrm{K}$ . Assume the doping concentration in the n region is  $N_d=10^{16}~\mathrm{cm^{-3}}$  and the doping concentration in the p region is  $N_a=6\times10^{15}~\mathrm{cm^{-3}}$ , and assume that a forward bias of  $0.60~\mathrm{V}$  is applied to the pn junction. Calculate the minority carrier concentrations at the edge of the space charge regions in a forward-biased pn junction.

# Example 1 Solution

$$n_{p}\left(-x_{p}\right)=n_{po}\exp\left(rac{eV_{a}}{kT}
ight) \quad ext{ and } \quad p_{n}\left(x_{n}
ight)=p_{no}\exp\left(rac{eV_{a}}{kT}
ight)$$

The thermal-equilibrium minority carrier concentrations are

$$n_{po} = \frac{n_i^2}{N_a} = \frac{\left(1.5 \times 10^{10}\right)^2}{6 \times 10^{15}} = 3.75 \times 10^4 \text{ cm}^{-3}$$

$$p_{\text{no}} = \frac{n_i^2}{N_d} = \frac{\left(1.5 \times 10^{10}\right)^2}{10^{16}} = 2.25 \times 10^4 \text{ cm}^{-3}$$

We then have

$$n_p(-x_p) = 3.75 \times 10^4 \exp\left(\frac{0.60}{0.0259}\right) = 4.31 \times 10^{14} \text{ cm}^{-3}$$

$$p_n(x_n) = 2.25 \times 10^4 \exp\left(\frac{0.60}{0.0259}\right) = 2.59 \times 10^{14} \text{ cm}^{-3}$$

We developed, in Chapter 6, the ambipolar transport equation for excess minority carrier holes in an n region. This equation, in one dimension, is

$$D_{p} \frac{\partial^{2} (\delta p_{n})}{\partial x^{2}} - \mu_{p} E \frac{\partial (\delta p_{n})}{\partial x} + g' - \frac{\delta p_{n}}{\tau_{p0}} = \frac{\partial (\delta p_{n})}{\partial t}$$

In the n region for  $x>x_n$ , we have that E=0 and g'=0. If we also assume steady state so  $\partial \left(\delta p_n\right)/\partial t=0$ , then Equation reduces to

$$\frac{d^2(\delta p_n)}{dx^2} - \frac{\delta p_n}{L_p^2} = 0 \quad (x > x_n)$$

where  $L_p^2 = D_p \tau_{p0}$ .

For the same set of conditions, the excess minority carrier electron concentration in the p region is determined from

$$\frac{d^2(\delta n_p)}{dx^2} - \frac{\delta n_p}{L_n^2} = 0 \quad (x < x_p)$$

where  $L_n^2 = D_n \tau_{n0}$ . The general solution to Equation 1 is

$$\delta p_n(x) = p_n(x) - p_{n0} = Ae^{x/L_p} + Be^{-x/L_p} \quad (x \ge x_n)$$

and the general solution to Equation 2 is

$$\delta n_p(x) = n_p(x) - n_{p0} = Ce^{x/L_n} + De^{-x/L_n} \quad (x \le -x_p)$$

The excess carrier concentrations are then found to be, for  $(x \ge x_n)$ ,

$$\delta p_n(x) = p_n(x) - p_{n0} = p_{n0} \left[ \exp\left(\frac{eV_a}{kT}\right) - 1 \right] \exp\left(\frac{x_n - x}{L_p}\right)$$
 and, for  $(x \le -x_p)$ ,

$$\delta n_p(x) = n_p(x) - n_{p0} = n_{p0} \left[ \exp\left(\frac{eV_a}{kT}\right) - 1 \right] \exp\left(\frac{x_p + x}{L_n}\right)$$

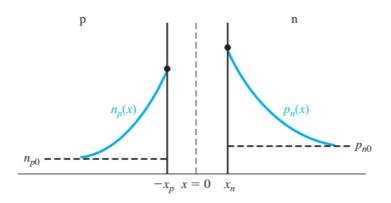


Figure: Steady-state minority carrier concentrations in a pn junction under forward bias.

In Chapter 6, we discussed the concept of quasi-Fermi levels, which apply to excess carriers in a nonequilibium condition. Since excess electrons exist in the neutral p region and excess holes exist in the neutral n region, we can apply quasi-Fermi levels to these regions. We had defined quasi-Fermi levels in terms of carrier concentrations as

$$p = p_o + \delta p = n_i \exp\left(\frac{E_{Fi} - E_{Fp}}{kT}\right)$$

and

$$n = n_o + \delta n = n_i \exp\left(\frac{E_{Fn} - E_{Fi}}{kT}\right)$$

Combining them, we can write

$$np = n_i^2 \exp\left(\frac{E_{Fn} - E_{Fp}}{kT}\right)$$

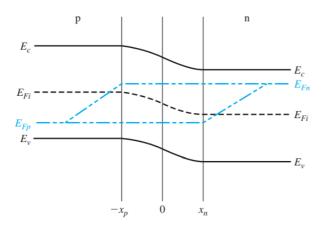


Figure: Quasi-Fermi levels through a forward-biased pn junction.

#### Ideal pn Junction Current

$$J_{p}(x_{n}) = \frac{eD_{p}p_{n0}}{L_{p}} \left[ \exp\left(\frac{eV_{a}}{kT}\right) - 1 \right]$$

$$J_{n}(-x_{p}) = \frac{eD_{n}n_{p0}}{L_{n}} \left[ \exp\left(\frac{eV_{a}}{kT}\right) - 1 \right]$$

The total current density in the pn junction is then

$$J = J_{p}(x_{n}) + J_{n}(-x_{p}) = \left[\frac{eD_{p}p_{n0}}{L_{p}} + \frac{eD_{n}n_{p0}}{L_{n}}\right] \left[\exp\left(\frac{eV_{a}}{kT}\right) - 1\right]$$

#### Ideal pn Junction Current

We may define a parameter  $J_s$  as

$$J_s = \left[ \frac{eD_p p_{n0}}{L_p} + \frac{eD_n n_{p0}}{L_n} \right]$$

so that Equation may be written as

$$J = J_{s} \left[ \exp \left( rac{eV_{a}}{kT} 
ight) - 1 
ight]$$

### Example 2

Consider a GaAs pn junction diode at  $T=300~\mathrm{K}$ . The parameters of the device are  $N_d=2\times10^{16}~\mathrm{cm^{-3}}, N_a=8\times10^{15}~\mathrm{cm^{-3}}, D_n=210~\mathrm{cm^2/s}, D_p=8~\mathrm{cm^2/s}, \tau_{no}=10^{-7}~\mathrm{s}$ , and  $\tau_{po}=5\times10^{-8}~\mathrm{s}$ . Determine the ideal reverse-saturation current density.

# Example 2 Solution

The ideal reverse-saturation current density is given by

$$J_s = \frac{eD_n n_{p0}}{L_n} + \frac{eD_p p_{n0}}{L_p}$$

which may be rewritten as

$$\begin{split} J_s &= e n_i^2 \left[ \frac{1}{N_a} \sqrt{\frac{D_n}{\tau_{no}}} + \frac{1}{N_d} \sqrt{\frac{D_\rho}{\tau_{po}}} \right] \\ &= \left( 1.6 \times 10^{-19} \right) \left( 1.8 \times 10^6 \right)^2 \\ &\times \left[ \frac{1}{8 \times 10^{15}} \sqrt{\frac{210}{10^{-7}}} + \frac{1}{2 \times 10^{16}} \sqrt{\frac{8}{5 \times 10^{-8}}} \right] \\ J_s &= 3.30 \times 10^{-18} \text{ A/cm}^2 \end{split}$$

#### Ideal I–V characteristic

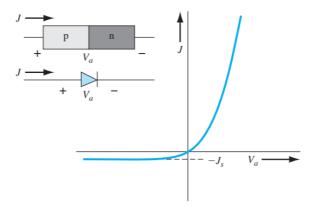


Figure: Ideal I-V characteristic of a pn junction diode

- The pn Junction Diode
  - pn Junction Current
  - Generation—Recombination Currents
  - High-Level Injection

#### Reverse-Biased Generation Current

$$R = \frac{-n_i}{\tau_{p0} + \tau_{n0}}$$

If we define a new lifetime as the average of  $\tau_{p0}$  and  $\tau_{n0}$ , or

$$\tau_0 = \frac{\tau_{p0} + \tau_{n0}}{2}$$

then the recombination rate can be written as

$$R = \frac{-n_i}{2\tau_0} \equiv -G$$

#### Reverse-Biased Generation Current

The negative recombination rate implies a generation rate, so G is the generation rate of electrons and holes in the space charge region. The generation current density may be determined from

$$J_{\rm gen} = \int_0^W eGdx$$

where the integral is over the space charge region. If we assume that the generation rate is constant throughout the space charge region, then we obtain

$$J_{\rm gen} = \frac{en_i W}{2\tau_0}$$

#### Forward-Bias Recombination Current

The recombination current density may be calculated from

$$J_{
m rec} = \int_0^W eRdx$$

where again the integral is over the entire space charge region. In this case, however, the recombination rate is not a constant through the space charge region. We have calculated the maximum recombination rate at the center of the space charge region, so we may write

$$J_{\rm rec} = ex' \frac{n_i}{2\tau_0} \exp\left(\frac{eV_a}{2kT}\right)$$

where x' is a length over which the maximum recombination rate is effective. However, since  $\tau_0$  may not be a well-defined or known parameter, it is customary to write

$$J_{\text{rec}} = \frac{eWn_i}{2\tau_0} \exp\left(\frac{eV_a}{2kT}\right) = J_{r0} \exp\left(\frac{eV_a}{2kT}\right)$$

#### Total Forward-Bias Current

In general, the diode current-voltage relationship may be written as

$$I = I_{s} \left[ \exp \left( \frac{eV_{a}}{nkT} \right) - 1 \right]$$

where the parameter n is called the ideality factor. For a large forward-bias voltage,  $n\approx 1$  when diffusion dominates, and for low forward-bias voltage,  $n\approx 2$  when recombination dominates. There is a transition region where 1< n< 2.

# Example 3

Consider a silicon pn junction diode at  $T=300~{\rm K}$  with parameters  $N_a=2\times$ 

 $10^{15}~{\rm cm^{-3}}, N_d = 8 \times 10^{16}~{\rm cm^{-3}}, D_p = 10~{\rm cm^2/s}, D_n = 25~{\rm cm^2/s},$  and  $\tau_0 = \tau_{p0} = \tau_{n0} = 10^{-7}~{\rm s}$ . The diode is forward biased at  $V_a = 0.35~{\rm V}$ .

- (a) Calculate the ideal diode current density.
- (b) Find the forward-biased recombination current density.
- (c) Determine the ratio of recombination current to the ideal diffusion current.

# Example 3 Solution

(a) 
$$J \cong J_s \exp\left(\frac{V_a}{V_t}\right)$$
 
$$J_s = e n_i^2 \left[\frac{1}{N_a} \sqrt{\frac{D_n}{\tau_{no}}} + \frac{1}{N_d} \sqrt{\frac{D_p}{\tau_{po}}}\right]$$
 
$$= \left(1.6 \times 10^{-19}\right) \left(1.5 \times 10^{10}\right)^2$$
 
$$\times \left[\frac{1}{2 \times 10^{15}} \sqrt{\frac{25}{10^{-7}}} + \frac{1}{8 \times 10^{16}} \sqrt{\frac{10}{10^{-7}}}\right]$$
 
$$J_s = 2.891 \times 10^{-10} \text{ A/cm}^2$$
 Then  $J \cong \left(2.891 \times 10^{-10}\right) \exp\left(\frac{0.35}{0.0259}\right)$  
$$= 2.137 \times 10^{-4} \text{ A/cm}^2$$

# Example 3 Solution

(b) 
$$V_{bi} = (0.0259) \ln \left[ \frac{(2 \times 10^{15})(8 \times 10^{16})}{(1.5 \times 10^{10})^2} \right]$$
  
= 0.7068 V

We find

$$W = \left\{ \frac{2(11.7) (8.85 \times 10^{-14}) (0.7068 - 0.35)}{1.6 \times 10^{-19}} \right.$$
$$\left. \times \left[ \frac{2 \times 10^{15} + 8 \times 10^{16}}{(2 \times 10^{15}) (8 \times 10^{16})} \right] \right\}^{1/2}$$
$$= 4.865 \times 10^{-5} \text{ cm}$$

# Example 3 Solution

Then

$$J_{rec} = \frac{en_i W}{2\tau_o} \exp\left(\frac{V_a}{2V_t}\right)$$

$$= \frac{\left(1.6 \times 10^{-19}\right) \left(1.5 \times 10^{10}\right) \left(4.865 \times 10^{-5}\right)}{2 \left(10^{-7}\right)} \times \exp\left[\frac{0.35}{2 (0.0259)}\right]$$

$$J_{rec} = 5.020 \times 10^{-4} \text{ A/cm}^2$$
(c)
$$\frac{J_{rec}}{J} = \frac{5.020 \times 10^{-4}}{2.137 \times 10^{-4}} = 2.35$$

- 1 The pn Junction Diode
  - pn Junction Current
  - Generation—Recombination Currents
  - High-Level Injection

# High-Level Injection

As the forward-bias voltage increases, the excess carrier concentrations increase and may become comparable or even greater than the majority carrier concentration.

$$np = n_i^2 \exp\left(\frac{V_a}{V_t}\right)$$

Under high-level injection, we may have  $\delta n > n_o$  and  $\delta p > p_o$  so that Equation becomes approximately

$$(\delta n)(\delta p) \cong n_i^2 \exp\left(\frac{V_a}{V_t}\right)$$

$$\delta n = \delta p \cong n_i \exp\left(\frac{V_a}{2V_t}\right)$$

The diode current is proportional to the excess carrier concentration so that, under high-level injection, we have

$$I \propto \exp\left(\frac{V_a}{2V_t}\right)$$

# High-Level Injection

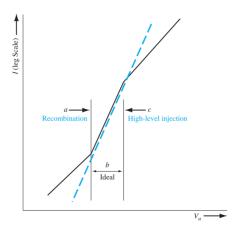


Figure: Forward-bias current versus voltage from low forward bias to high forward bias

#### **END**

# **Thanks**